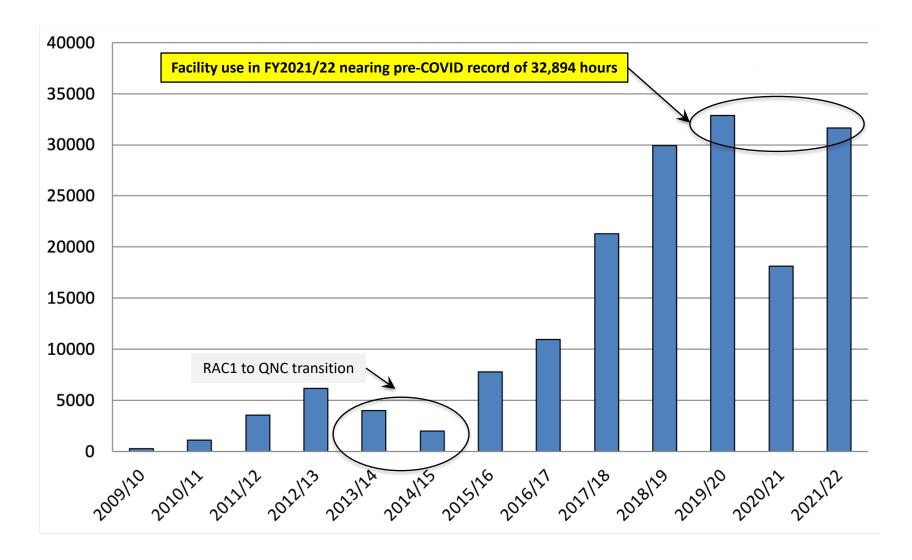
Quantum-Nano Fabrication & Characterization Facility (QNFCF)

Core Scientific Research Platform



Hours of equipment use invoiced per fiscal year*

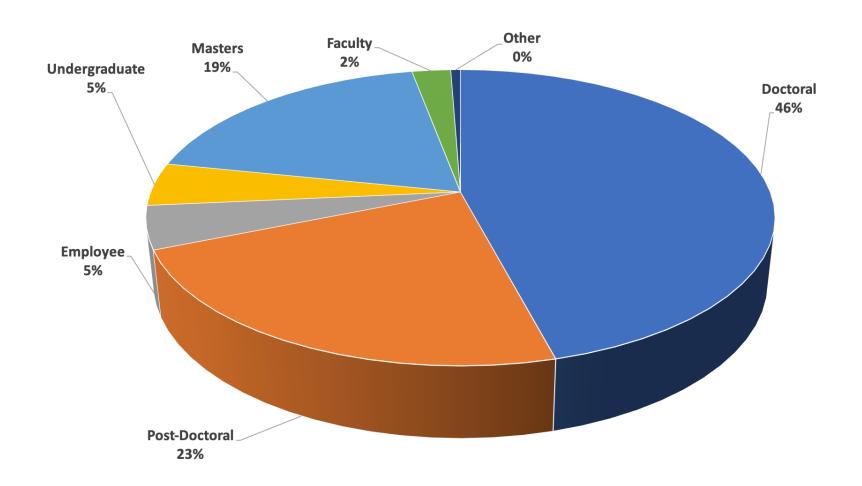
* Fiscal years ending April 30 - graph does not include user training & support hours logged by QNFCF staff



2

July 2022

Well used by broad range of Lab Members (Users)



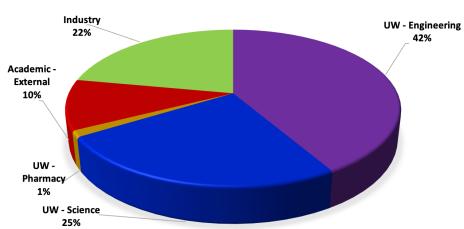


FY2021/22: 215 Users under 77 distinct research groups

Principal Investigator	Hours of Equip Use Logged	Category: Academic, Industry, Govt, Other	Institution / Company Name	Faculty	Department Sys Design En	
Abdel-Rahman, Eihab	20	Academic	UWaterloo	Engineering		
Alfano, Marco	34	Academic	UWaterloo	Engineering	MME	
Bajcsy, Michal	454	Academic	UWaterloo	Engineering	ECE	
Ban, Dayan	594	Academic	UWaterloo	Engineering	ECE	
Basha, Mohamed	3	Academic	UWaterloo	Engineering	ECE	
Cui, Bo	3291	Academic	UWaterloo	Engineering	ECE	
Goldthorpe, Irene	39	Academic	UWaterloo	Engineering	ECE	
Karim, Karim	147	Academic	UWaterloo	Engineering	ECE	
Kim, Na Young	117	Academic	UWaterloo	Engineering	ECE	
Levine, Peter	55	Academic	UWaterloo	Engineering	ECE	
Mansour, Raafat	840	Academic	UWaterloo	Engineering	ECE	
Mayer, Michael	12	Academic	UWaterloo	Engineering	MME	
Miao, Guo-Xing	686	Academic	UWaterloo	Engineering	ECE	
Mitra, Sushanta	95	Academic	UWaterloo	Engineering	MME	
Musselman, Kevin	25	Academic	UWaterloo	Engineering	MME	
Pope, Michael	32	Academic	UWaterloo	Engineering	Chem Eng	
Poudineh, Mahla	163	Academic	UWaterloo	Engineering	ECE	
Reimer, Michael	748	Academic	UWaterloo	Engineering	ECE	
Safavi-Naeini, Safieddin	141	Academic	UWaterloo	Engineering	ECE	
Shahsavan, Hamed	163	Academic	UWaterloo	Engineering	Chem Eng	
Sivoththaman, Siva	46	Academic	UWaterloo	Engineering	ECE	
Wasilewski, Zbig	163	Academic	UWaterloo	Engineering	ECE	
Wei, Lan	18	Academic	UWaterloo	Engineering	ECE	
Wilson, Chris	1498	Academic	UWaterloo	Engineering	ECE	
Wong, William	575	Academic	UWaterloo	Engineering	ECE	
Wu, Yimin	153	Academic	UWaterloo	Engineering	MME	
Yavuz, Mustafa	556	Academic	UWaterloo	Engineering	MME	
Yeow, John	1533	Academic	UWaterloo	Engineering	Sys Design En	
Yim, Evelyn	114	Academic	UWaterloo	Engineering	Chem Eng	
Yu, Alfred	48	Academic	UWaterloo	Engineering	ECE	
Zhao, Boxin	6	Academic	UWaterloo	Engineering	Chem Eng	
Zhou, Norman	22	Academic	UWaterloo	Engineering	MME	
Slavcev, Roderick	54	Academic	UWaterloo	Pharmacy	Pharmacy	
Baugh, Jonathan	2765	Academic	UWaterloo	Science	Chemistry	
Budakian, Raffi	574	Academic	UWaterloo	Science	Physics	
Cory, David	581	Academic	UWaterloo	Science	Chemistry	
Forrest, James		Academic	UWaterloo	Science	Physics	
Hawthorn, David	20		UWaterloo	Science	Physics	
Islam, Rajibul		Academic	UWaterloo	Science	Physics	
Jennewein, Thomas		Academic	UWaterloo	Science	Physics	
Kycia, Jan	2	Academic	UWaterloo	Science	Physics	
Lupascu, Adrian	393	Academic	UWaterloo	Science	Physics	
Maheshwari, Vivek			UWaterloo	Science	Chemistry	
Mariantoni, Matteo	198		UWaterloo	Science	Physics	
Nazar, Linda		Academic	UWaterloo	Science	Chemistry	
Pushin, Dmitry	607	Academic	UWaterloo	Science	Physics	
Resch, Kevin	4	Academic	UWaterloo	Science	Physics	
Schipper, Derek		Academic	UWaterloo	Science	Chemistry	
Sciaini, German		Academic	UWaterloo	Science	Chemistry	
Senko, Crystal	1137	Academic	UWaterloo	Science	Physics	
Strickland, Donna	32		UWaterloo	Science	Physics	
Janakianu, Dollila	and, Donna 32 Academic Vei 404 Academic		O ** d(C) 100	SCIENCE	11193163	

Principal Investigator Hours of Equip Use Logged		Category: Academic, Industry, Govt, Other	Institution / Company Name	Faculty	Department	
Reznik, Alla	11	Academic - External	Lakehead University	n/a	n/a	
Hryciw, Aaron	3	Academic - External	University of Alberta	n/a	n/a	
Dolgaleva, Ksenia	0.22	Academic - External	University of Ottawa	n/a	n/a	
Ahmed, Marya	1.23	Academic - External	University of PEI	n/a	n/a	
Helmy, Amr	1578	Academic - External	University of Toronto	n/a	n/a	
Howe, Jane	0.02	Academic - External	University of Toronto	n/a	n/a	
Kherani, Nazir	78	Academic - External	University of Toronto	n/a	n/a	
Miller, RJ Dwayne	19	Academic - External	University of Toronto	n/a	n/a	
Phillips, Michael	17	Industry	Vena Medical Holdings Inc	n/a	n/a	
Fathi, Ehsan	209	Industry	VueReal Inc	n/a	n/a	
Weedbrook, Christian	53	Industry	Xanadu Quantum Technologies	n/a	n/a	
Galaom, Ahmed	649	Industry	Sheba Microsystems	n/a	n/a	
Xiang, Jingen	350	Industry	SpinQ Technology Co. Ltd	n/a	n/a	
Peinke, Emanuel	256	Industry	TandemLaunch Inc.	n/a	n/a	
Rezazadeh, Vallen	13	Industry	TransEON Inc.	n/a	n/a	
Khosraviani, Kourosh	106	Industry	Adhawk Microsystems	n/a	n/a	
Robson, Mitch	280	Industry	Ambature Inc.	n/a	n/a	
Najafi-Yazdi, Alireza	783	Industry	Anyon Systems Inc.	n/a	n/a	
Marsh, Lee	243	Industry	Bio-Stream Diagnostics Inc.	n/a	n/a	
Boorn, Andrew	9	Industry	High Q Technologies, LP	n/a	n/a	
Morris, David	82	Industry	ICSPI Corp.	n/a	n/a	
MacLean, Steve	97	Industry	Infinite Potential Laboratories	n/a	n/a	
Hamilton, P. (UW Velocity)	40	Industry	LSK Technologies	n/a	n/a	
Akhlaghi, Mohsen	788	Industry	Photonic Inc.	n/a	n/a	
Shaffer, James	272	Industry	Quantum Valley Ideas Lab	n/a	n/a	

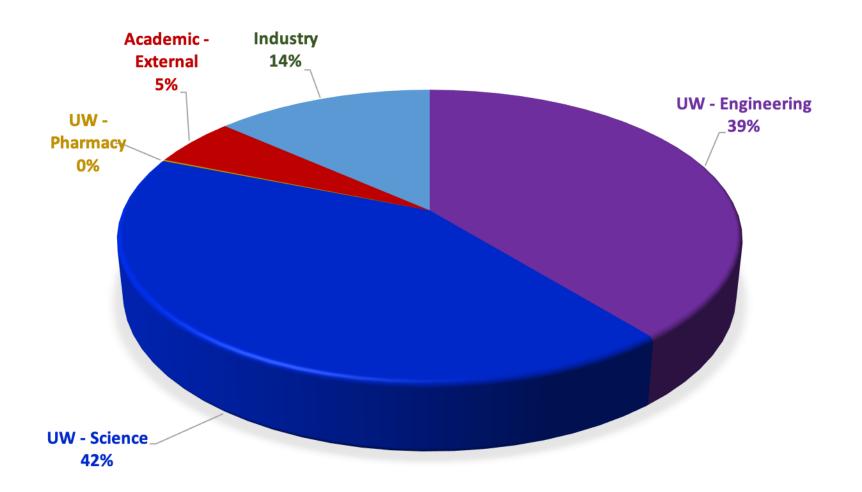
QNFCF PI BREAKDOWN AS A FUNCTION OF AFFILIATION (FY2021/22)





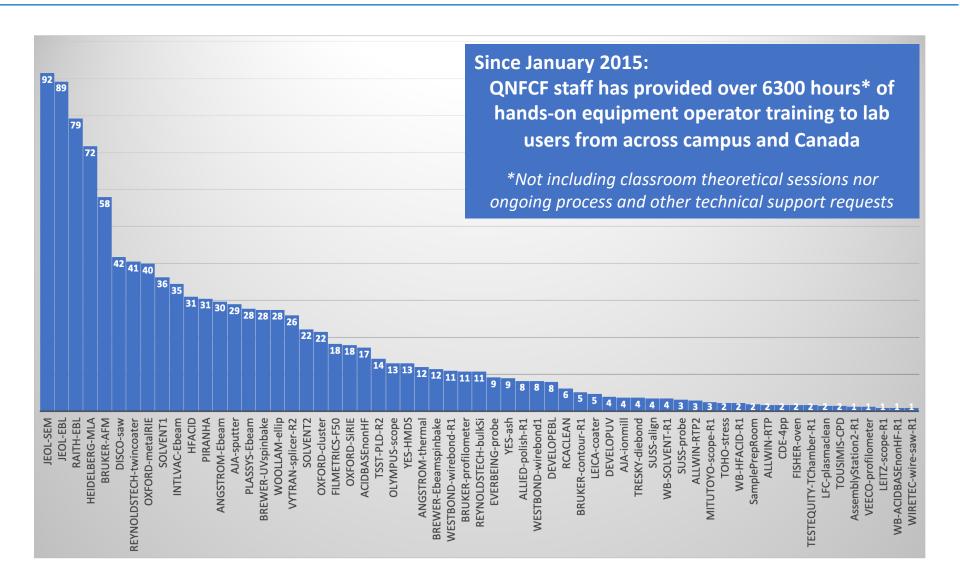
July 2022

FY2021/22: % of total hours of use per category of affiliation





FY2021/22: Logged 1114 Hours of hands-on training





Annual O&M expenses and User fees trends*

* Fiscal years ending April 30

EXPENSES	2012	2013	2014	2015	2016	2017	2018	2019	2020	2021	2022	Average Last 3 Years
SALARIES & BENEFITS												
Sub-Total:	\$222,645	\$274,113	\$290,309	\$365,712	\$460,623	\$613,184	\$819,592	\$1,535,502	\$1,701,655	\$1,778,492	\$1,806,057	\$1,762,068
SUPPLIES, MAINTENANCE & REPAIRS												
Sub-Total:	\$101,393	\$122,271	\$506,975	\$405,379	\$589,031	\$802,204	\$1,163,558	\$1,380,003	\$1,400,137	\$1,071,837	\$1,082,626	\$1,184,867
TOTAL:	\$324,038	\$396,384	\$797,285	\$771,091	\$1,049,653	\$1,415,388	\$1,983,150	\$2,915,505	\$3,101,791	\$2,850,329	\$2,888,683	\$2,946,934
USER FEES COLLECTED	\$86,583	\$157,915	\$111,333	\$80,860	\$348,371	\$539,638	\$994,730	\$1,376,704	\$1,763,769	\$877,024	\$1,320,204	\$1,320,332
											<u>-</u>	
% EXPENSES COVERED BY USER FEES	27%	40%	14%	10%	33%	38%	50%	47%	57%	31%	46%	45%



Background Information



QNFCF Overview

\$63M in Capital Investments

QNC Building

\$25M ISO 4 rated Cleanroom

VC-G rated Metrology labs

\$26M Lab equipment

RAC1 Building

\$1M ISO 6 rated Cleanroom

\$1M Lab equipment

RAC2 Building

\$10M Lab equipment















Distributed across 13 sites on campus **TEM Lab** QNC **Packaging** FIB Lab Lab QNC QNC **TEM** Fab Sample Sample Prep Lab Prep Lab QNC QNC **Primary** NanoFab Software Charact Lab Lab 1 Cleanroom ONC RAC2 QNC Clean Charact Assembly Lab 2 Cleanroom RAC2 RAC1 Inert Growth **Atmosphere** Lab₁ Lab Growth RAC2 RAC1 Lab 2 RAC2 WATERLOO | QNF

Broad Range of Capabilities

Deposition

- 1. ALD / PECVD Cluster Deposition System
- 2. LPCVD Low Temperature Oxidation (LTO) Furnace
- 3. LPCVD Poly Silicon and Silicon Carbide Furnace
- 4. LPCVD Silicon Nitride Furnace
- 5. Rapid Thermal Processor #1 (RTP)
- 6. Rapid Thermal Processor #2 (RTP)
- 7. PVD E-Beam & Resistive Heating Thermal Evaporator
- 8. PVD E-Beam Long Throw Evaporator
- 9. PVD Nb Superconducting Films Sputter System
- 10. PVD Twin Chamber Sputter System
- 11. PVD Al Superconducting Films Evaporator System
- 12. PVD Thermal Evaporator for P-Type Contacts
- 13. Thermal Oxidation Furnace

Lithography

- 1. E-Beam Lithography System (30kV)
- 2. E-Beam Lithography System (100kV)
- 3. Beamer/Tracer Software Suite
- 4. Front/Back Mask Aligner
- 5. Wafer Bonder
- 6. UV Direct Write Lithography System
- 7. Oven: Convection
- 8. Oven: HMDS & Image Reversal
- 9. Spin Coater: Dual General Purpose Hood
- 10. Spin Coater: E-Beam Resists
- 11. Spin Coater: UV Resists

Dry Etch

- 1. Ion Mill
- 2. Photoresist Strip
- 3. RIE: Deep Silicon Etch (DRIE)
- 4. RIE: Metal & III-V Materials

Wet Benches

- 1. Bulk Silicon Etch
- 2. Critical Point Dryer
- 3. Diffusion Pre-Clean (RCA Chemistries)
- 4. E-Beam Resist Develop
- 5. HF Acids Only
- 6. Non-HF Acids & Bases
- 7. Piranha Organics Clean & Resist Strip
- 8. Solvent Processing Station #1
- 9. Solvent Processing Station #2
- 10. UV Resist Develop

Characterization

- 1. Bruker Atomic Force Microscope
- 2. Scanning Electron Microscope
- 3. Manual Cleaving Tool
- 4. 4-Point Probe
- 5. Electrical Prober Station: Generous donation from EVERBEING
- 6. Electrical Probe Station
- 7. Ellipsometer
- 8. Microscope #1
- 9. Microscope #2
- 10. Reflectometer: Thin Film Mapping
- 11. Reflectometer: Thin Film Spot Measurement
- 12. Surface Profiler #1
- 13. Surface Profiler #2
- 14. Wafer Stress Measurement
- 15. SEM Sample Coater

Packaging Lab

- 1. Convection Cure Oven
- 2. Dicing Saw
- 3. Die Bonder
- 4. H2 Plasma Cleaner
- 5. Measurement Microscope
- 6. Wirebonder: Manual Wedge/Ball
- 7. Wirebonder: Semi-automatic Wedge
- 8. Wire Pull Tester
- 9. Epoxy dispenser

QNC Metrology Labs

- 1. SEM/FIB System
- 2. S/TEM System
- 3. Sample Prep Polisher
- 4. Sample Prep Microscope
- 5. Sample Prep Multi-tool
- 6. Sample Prep Dimpler
- 7. Sample Prep Saw
- 8. Sample Prep Ion Mill
- 9. Sample Prep Grinder/Polisher

RAC1 Labs

- 1. Assembly Station #1
- 2. Assembly Station #2
- 3. Environmental Chamber
- 4. Laser Welder
- 5. Sample Cutter
- 6. Sample Lapper
- 7. Wire Saw
- 8. Microscope #1
- 9. Microscope #2
- 10. Microscope #3
- 11. 02/Ar Plasma Cleaner
- 12. Wet Bench: Non-HF Acids & Bases
- 13. Wet Bench: HF Acids
- 14. Wet Bench: Solvent Processing
- 15. Wire Bonder
- 16. 3D Optical Surface Profiler

RAC2 Labs

- 1. Fiber Splicer
- 2. Microscope #2
- 3. Veeco Atomic Force Microscope
- 4. LPCVD for Carbon Nanotube Growth
- 5. LPCVD for Silicon Nanowire Growth
- 6. Pulsed Laser Deposition System

Key QNFCF success factors

- 1. Outstanding multi-year financial support from IQC and CFREF-TQT
- 2. Rare ensemble of lab equipment backed by solid expertise
- 3. QNFCF Team with extensive technical & operations experience
- 4. Strong focus on customer service
- 5. Revision-tracked SOPs / well-characterized recipes / process support
- 6. Extensive, mandatory training
- 7. Stable, professionally-maintained lab equipment & infrastructure
- 8. Clearly defined, communicated & enforced policies (fair access to all)
- 9. UWaterloo's "creator owned" IP policy